Application No. 10/659,190 Reply to Office Action of June 15, 2006

Amendments to and Listing of the Claims:

Please amend claims 6 and 10 and cancel claim 8, so that the claims read as follows:

- 1-5. (Cancelled)
- 6. (Currently Amended) A method of producing a semiconductor device, comprising a step of forming a copper wiring by chemical mechanical polishing and washing with washing liquid for a semiconductor substrate comprising a basic compound quaternary ammonium hydroxide and mannitol.
 - 7. (Cancelled)
 - 8. (Cancelled)
- 9. (Previously Presented) The method according to claim 6, wherein the concentration of the mannitol is from 0.01 to 5 wt%.
- 10. (Currently Amended) The method according to claim 6, wherein the concentration of the basic compound quaternary ammonium hydroxide is from 0.05 to 1 wt%.

2

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